



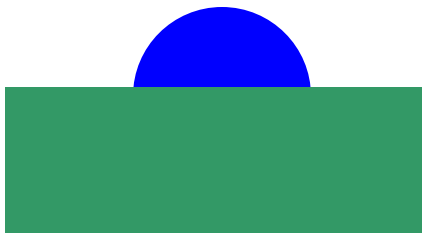
CONSULTING LTD

Managing flexible webs for vacuum roll-to-roll deposition for electronic or ultra-barrier applications

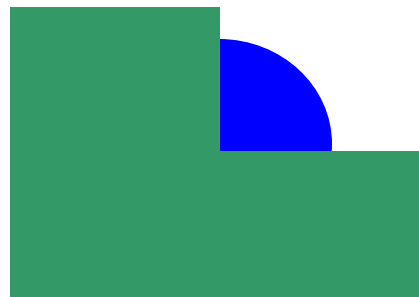
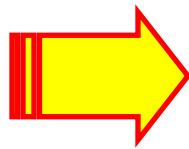
Dr Charles A Bishop
C.A.Bishop Consulting Ltd
www.cabuk1.co.uk

Nucleation

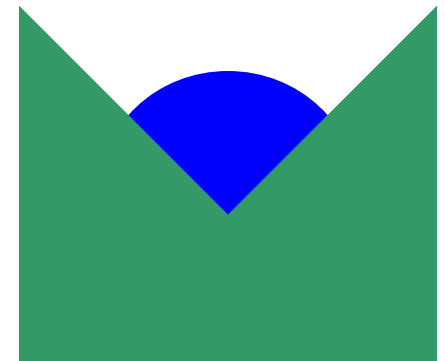
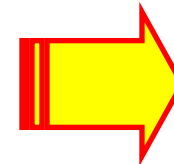
minimising surface energy



untextured
surface

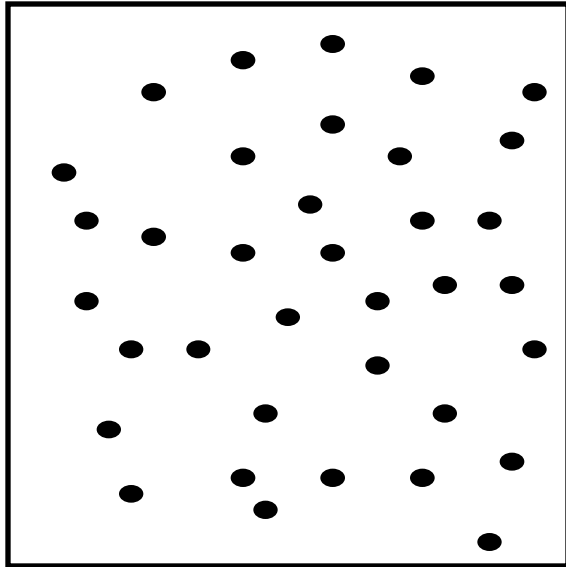


reduced surface
energy

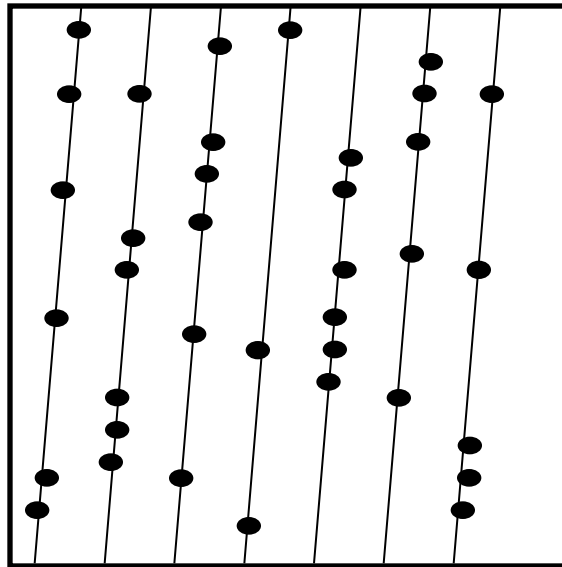


lowest surface
energy

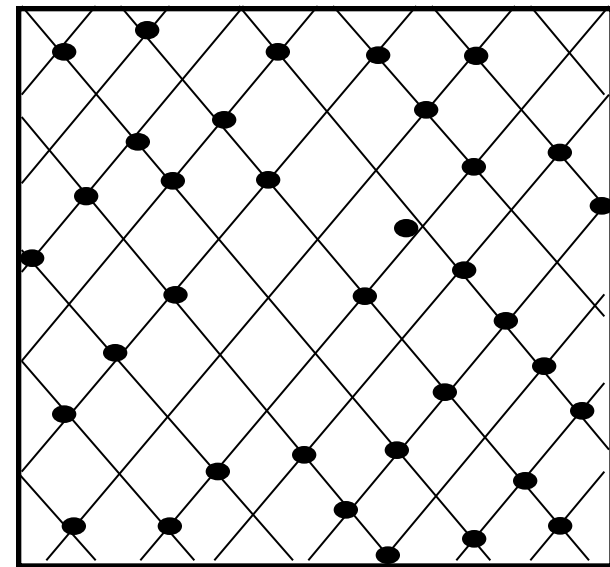
Influence of texture on nucleation



no texture -
random
nucleation



simple grooves
preferred nucleation
in grooves



crossed grooves
preferred nucleation
in pyramid pits

Texture

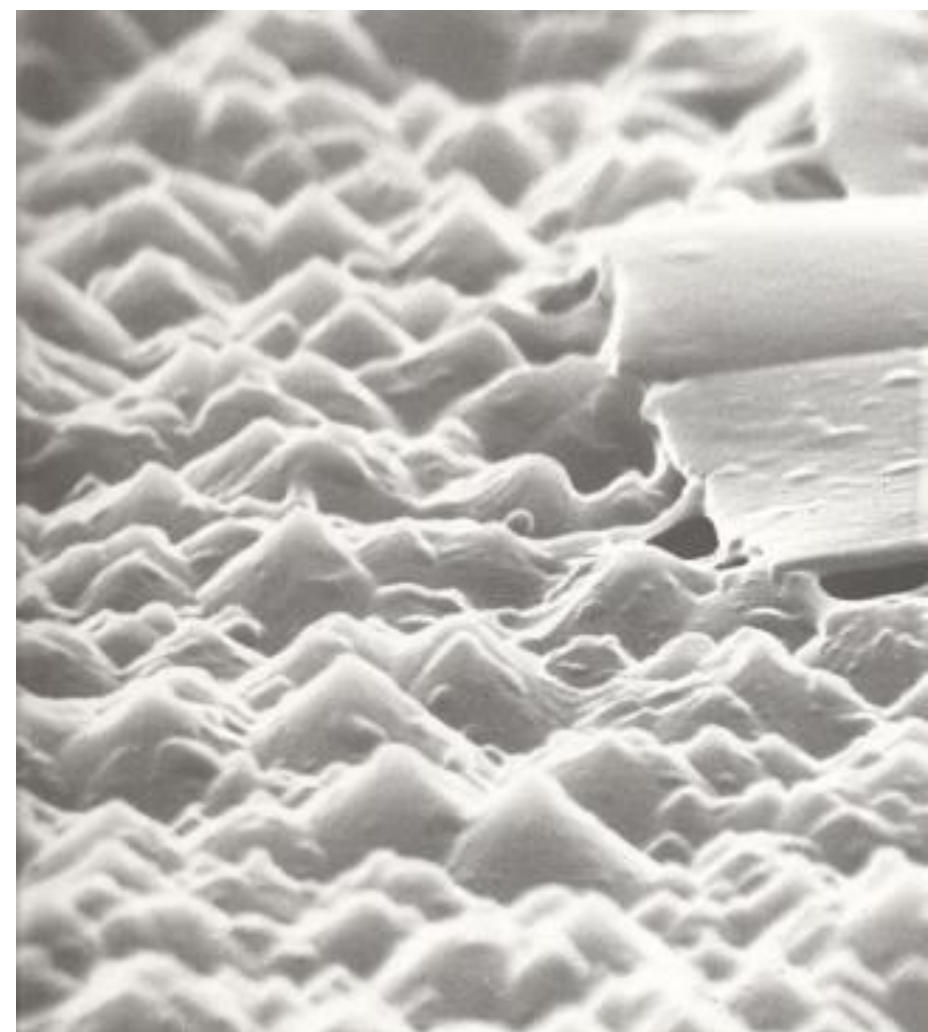
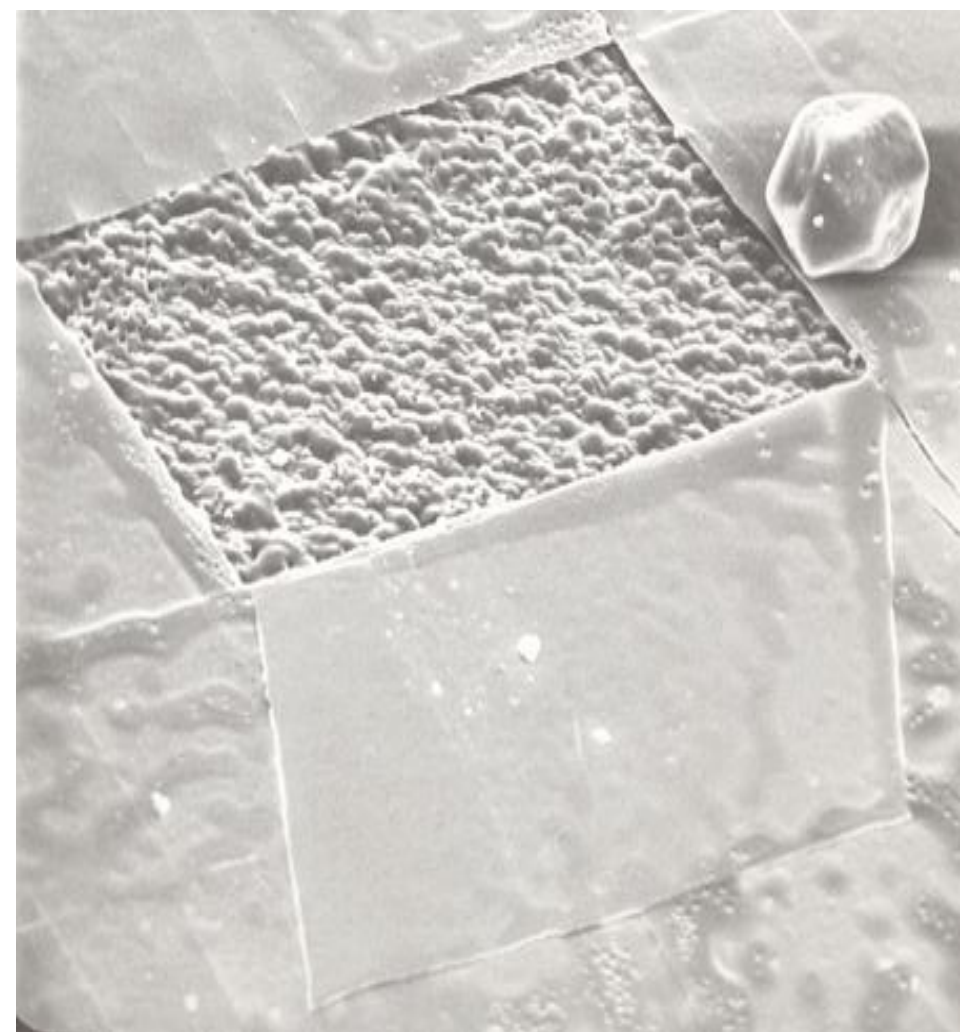
Random

- Chemical etching
 - Laser ablation/etching
 - Plasma etching
 - Hairy surface
- } similar

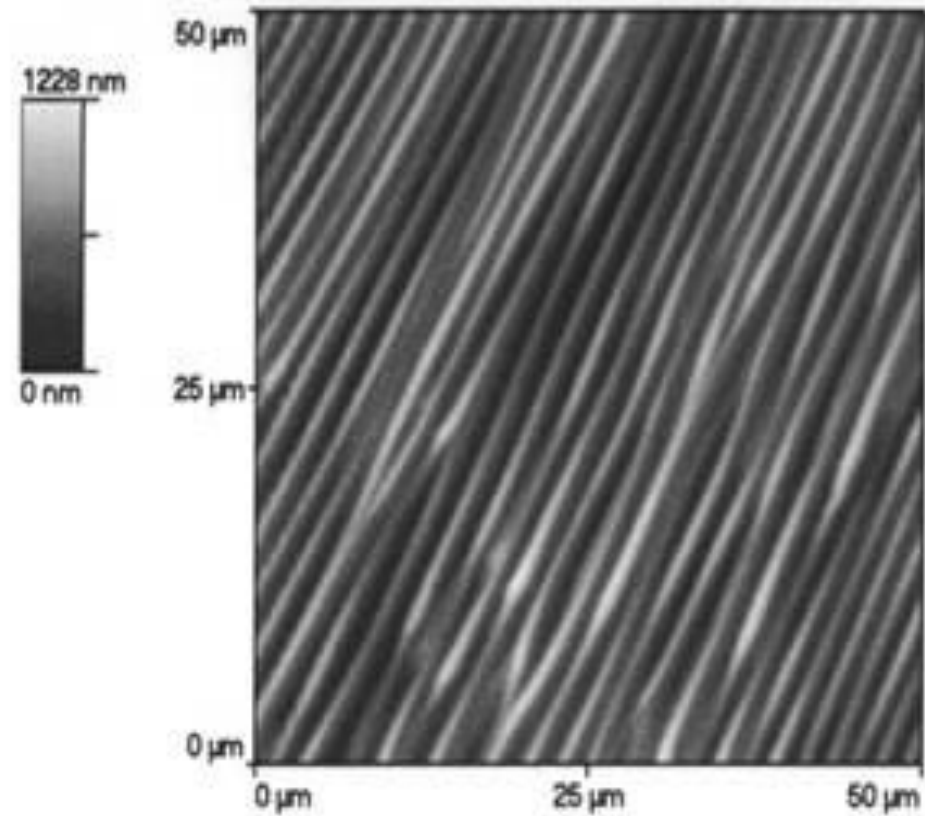
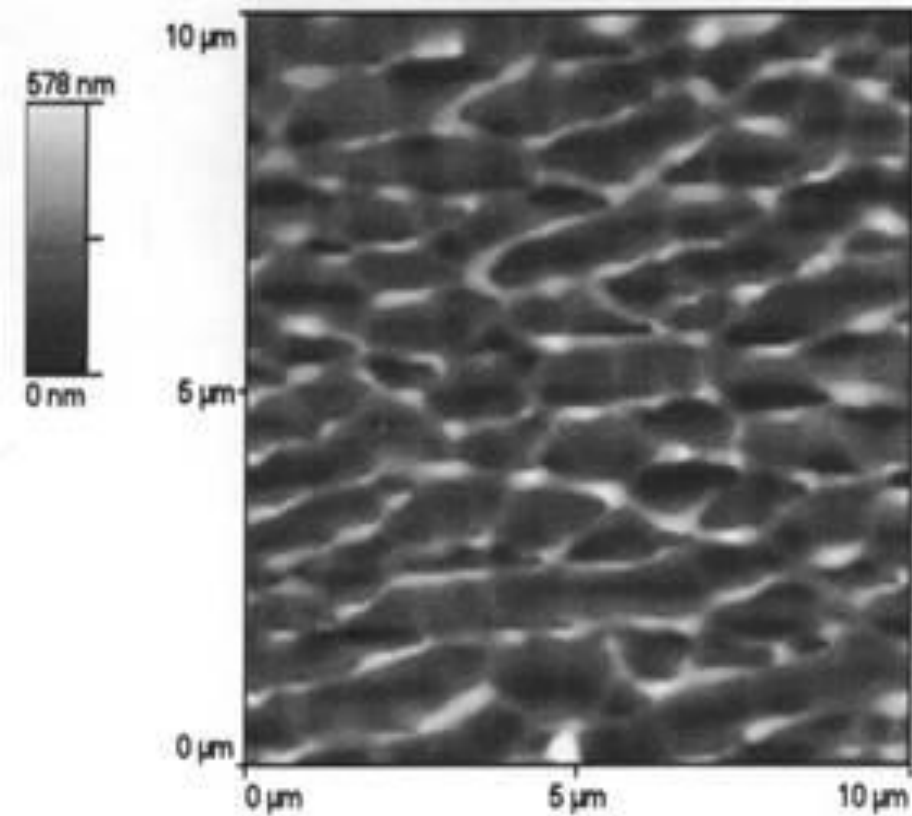
Regular

- Laser writing
- Printing
- Embossing

Orthochlorophenol etched polyester

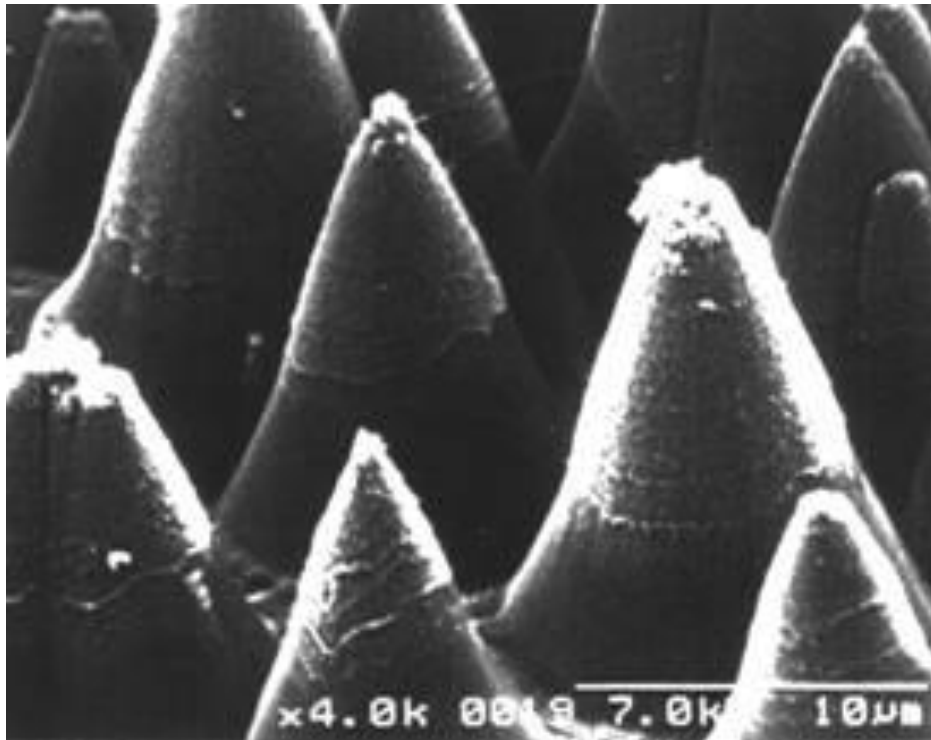


Laser ablation/etching

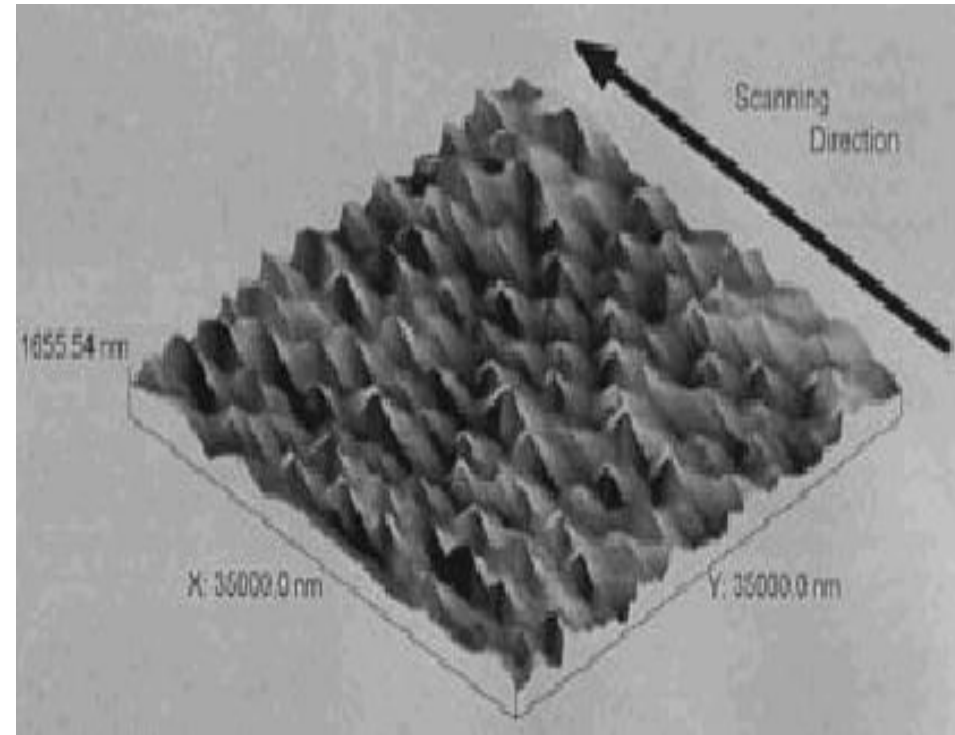


Atomic force microscope picture of the surface structure developed on the ablated PET film at 0 and 85 degrees. Dyer et al. Hull Univ.

Laser ablation/etching

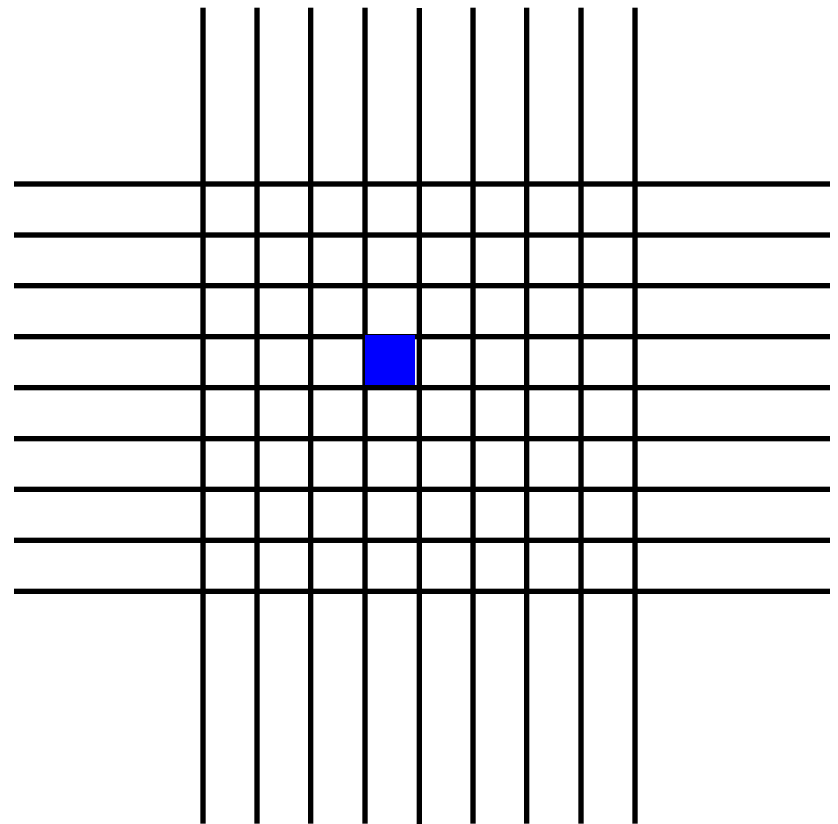
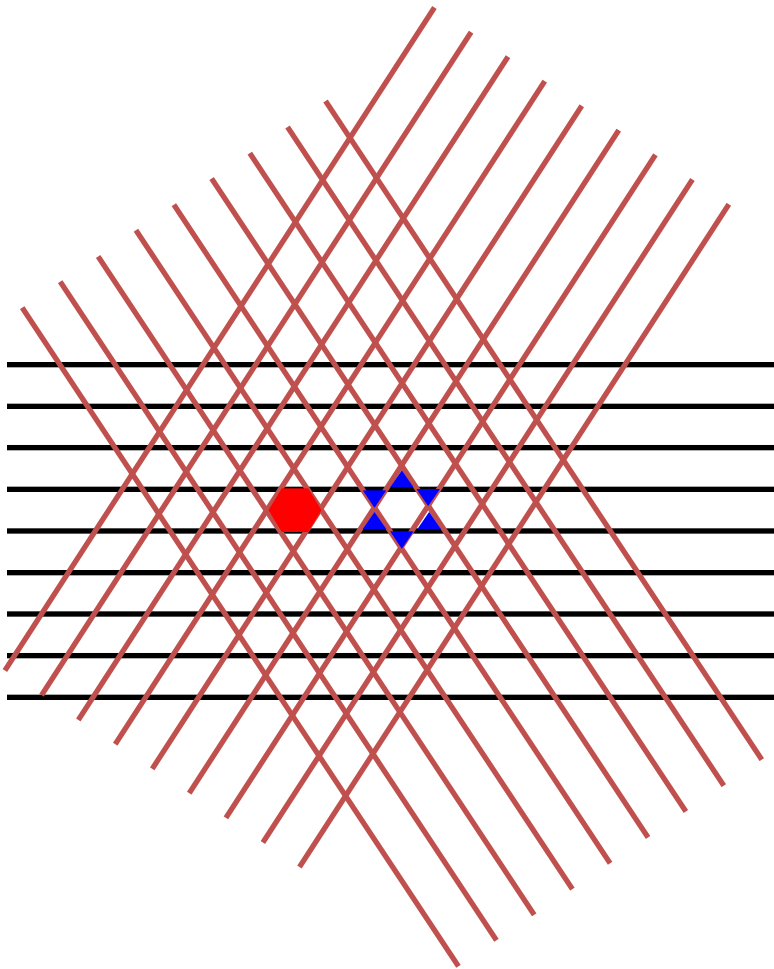


Scanning electron microscope picture of the developed conical structure on excimer laser irradiated polyimide at 74.4 mJ/cm² fluence.

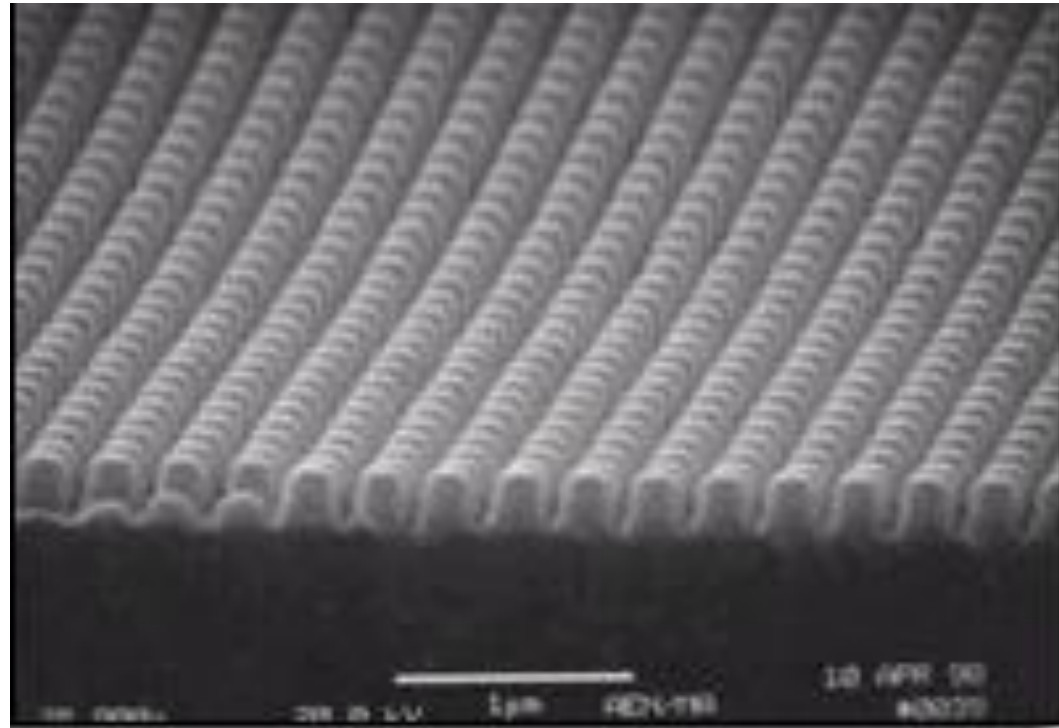
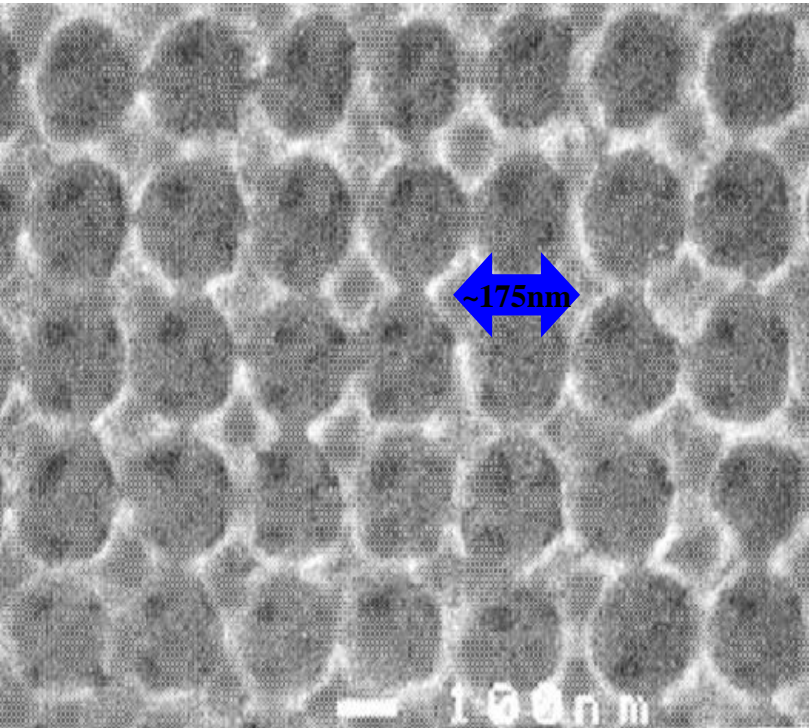


AFM picture of the developed conical structure on excimer laser irradiated polyester at 600 - 1000 mJ/cm² fluence. Rossier et al. Lausanne Polytechnic Langmuir 1999 15, 5173-5178

Intersecting gratings

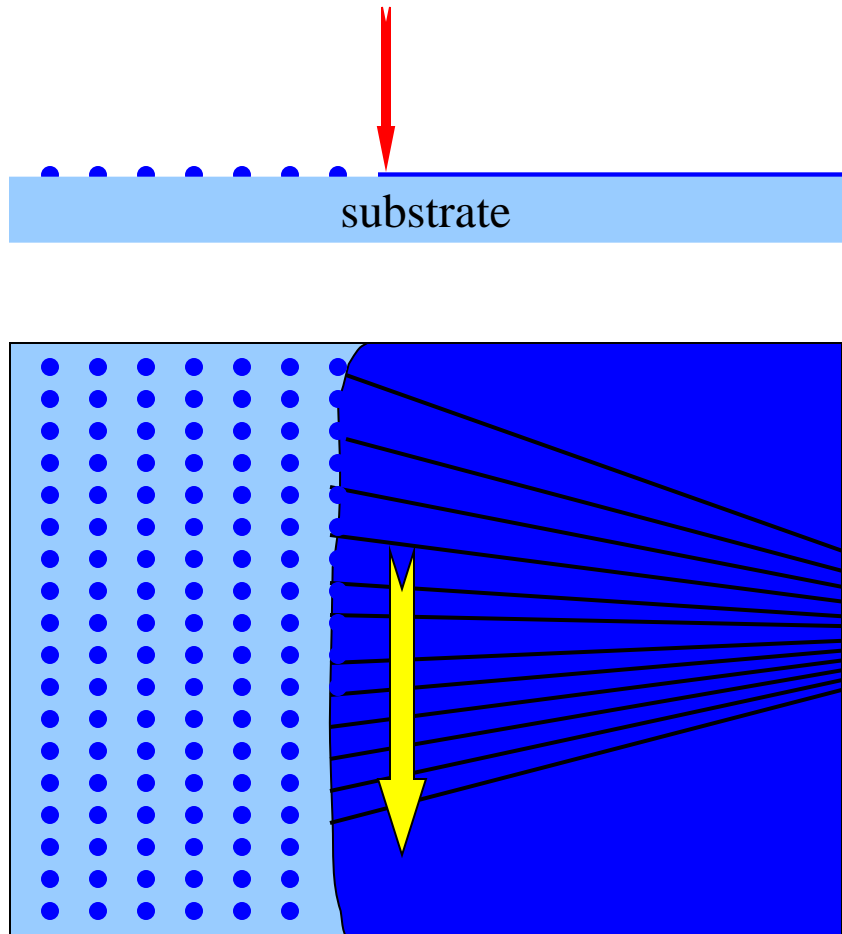


Micrographs - holographic surfaces



**300nm pitch replicated holographic motheye
Structure produced by Holographix**

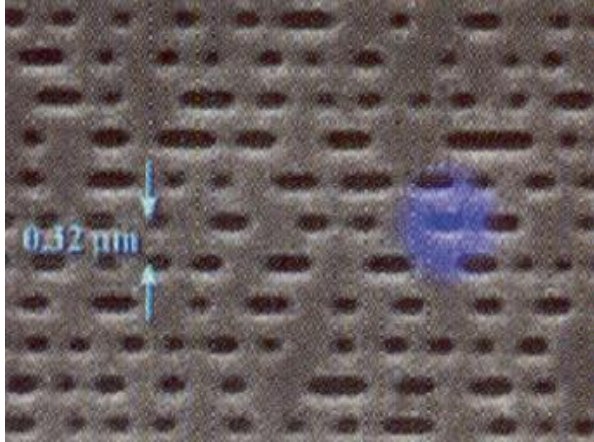
Laser agglomeration or reticulation



Laser scans from spot to spot on thin film causing reticulation of the film into islands

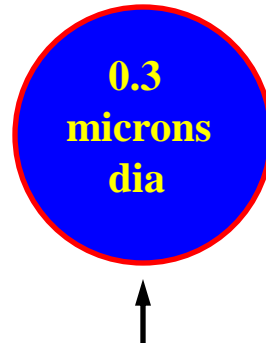
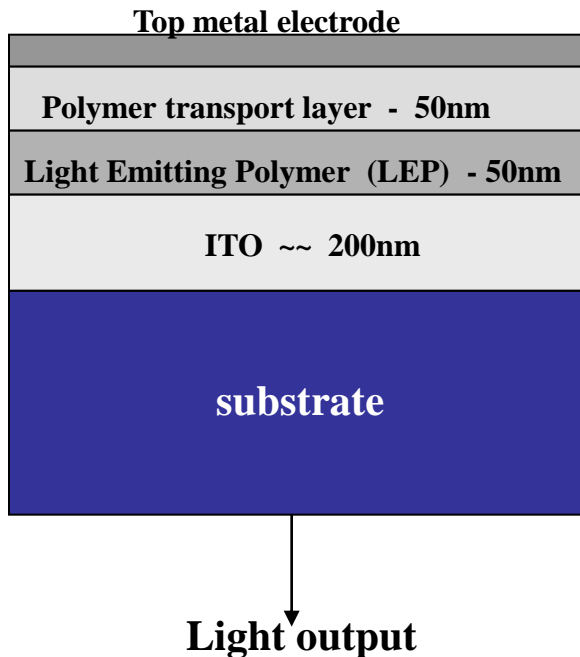
This requires a good quality very thin continuous coatings to shrink into uniform size islands

DVR blue laser 400nm
track spacing 0.32 microns

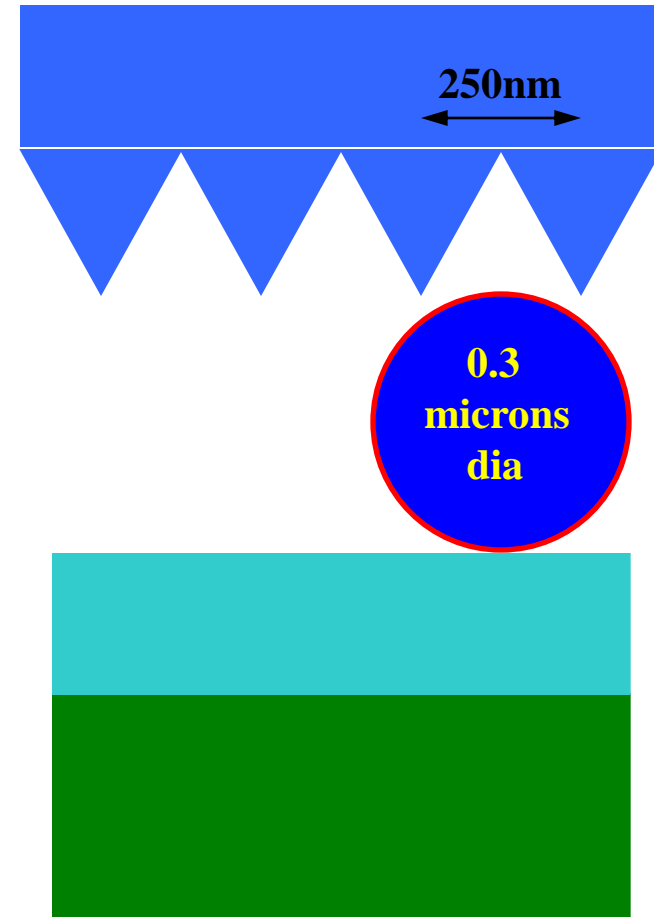


Debris –

the need for cleaning

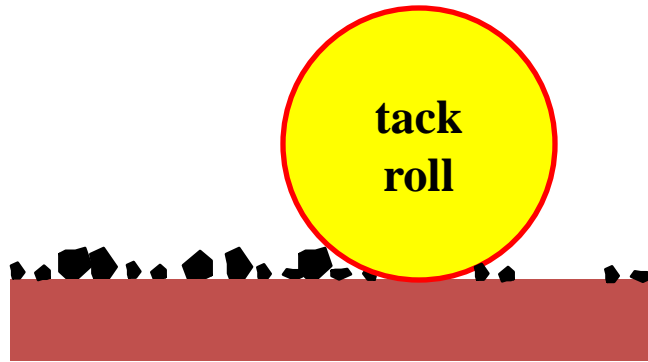


residual debris is of the same size as the total thickness of OLED coatings or pitch of the embossed grating or track spacing of blue laser DVR

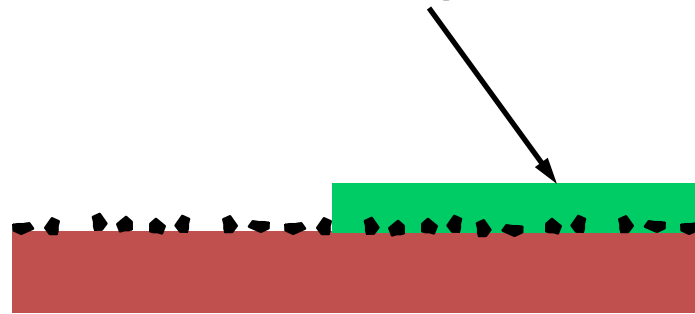


Starting process steps

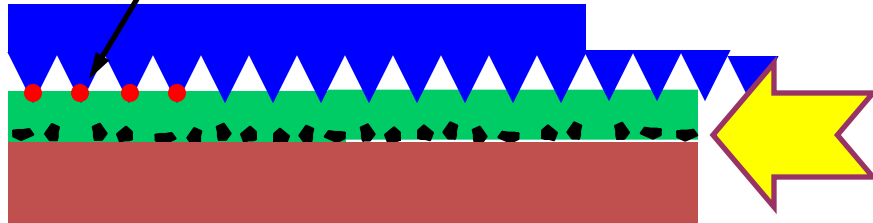
Clean surface



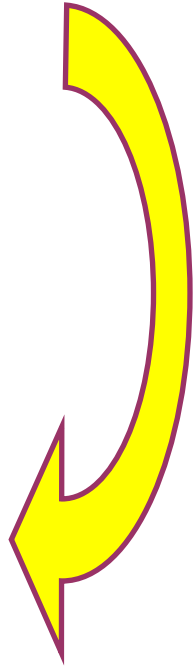
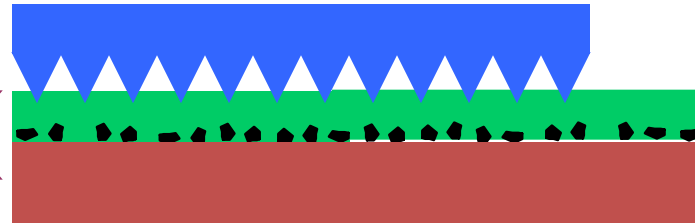
Polymer smoothing layer -
to cover remaining debris



Nucleation into
micro/nano-embossed surface

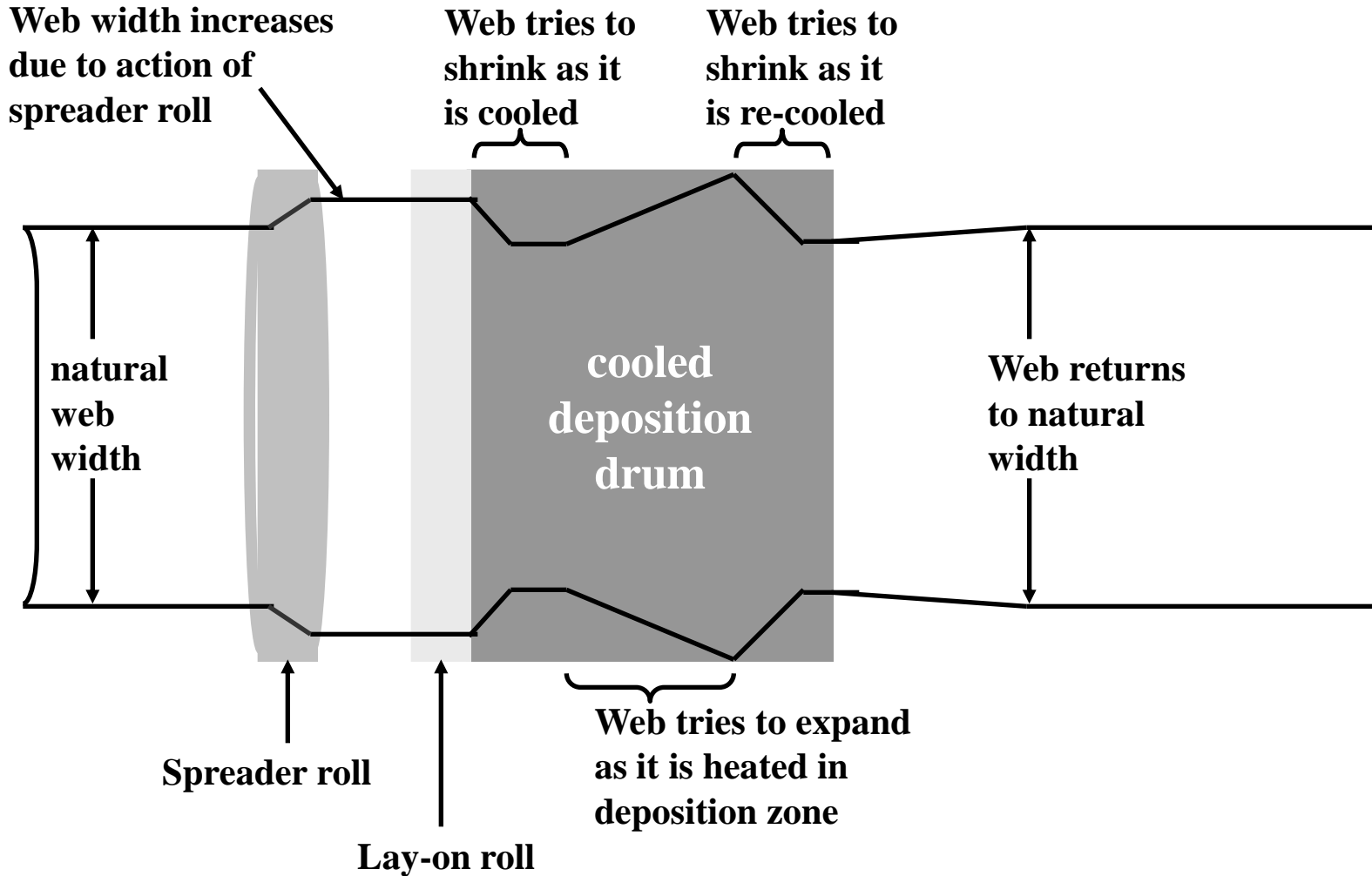


Emboss surface



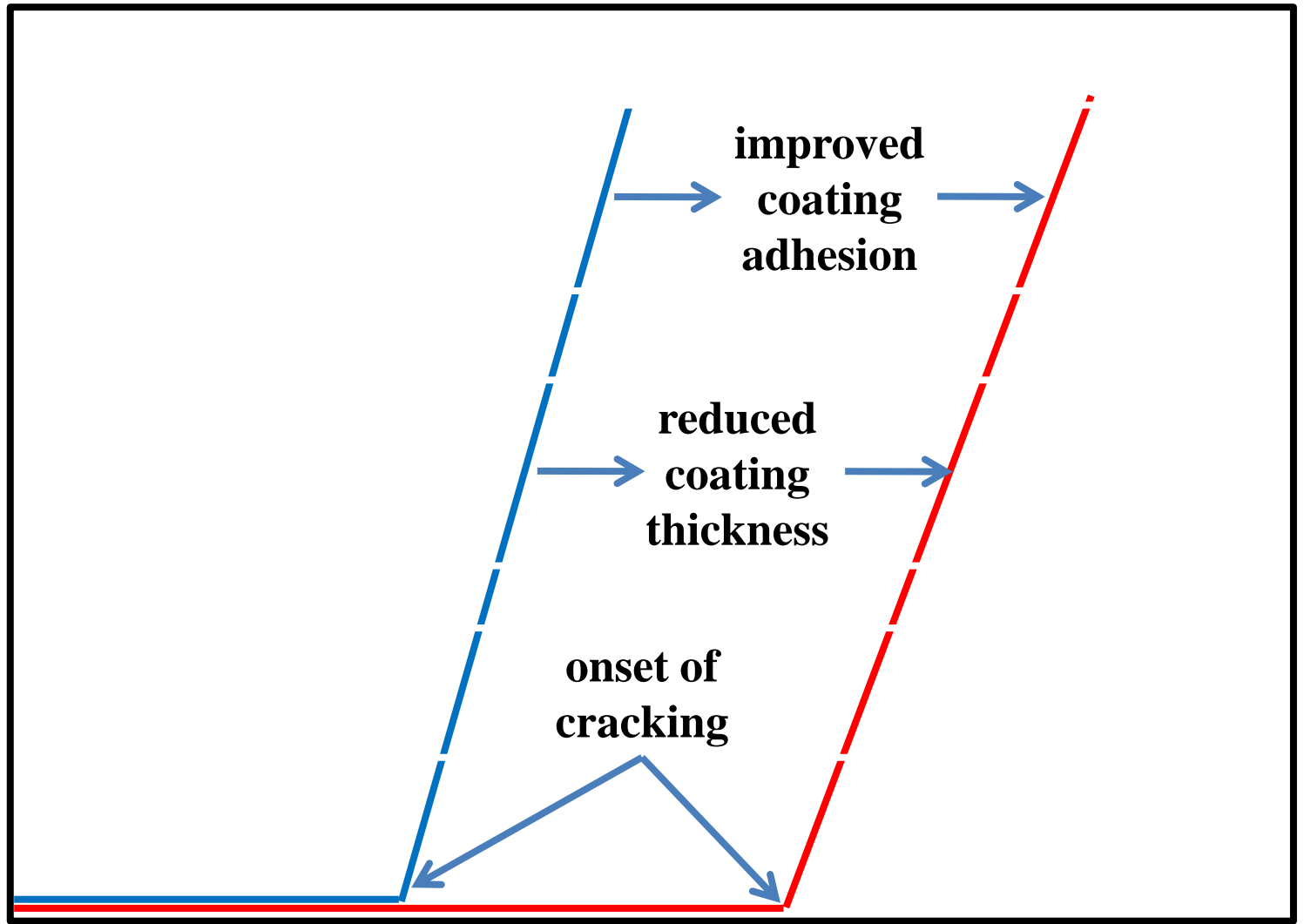
Polymer films

Web dimension changes



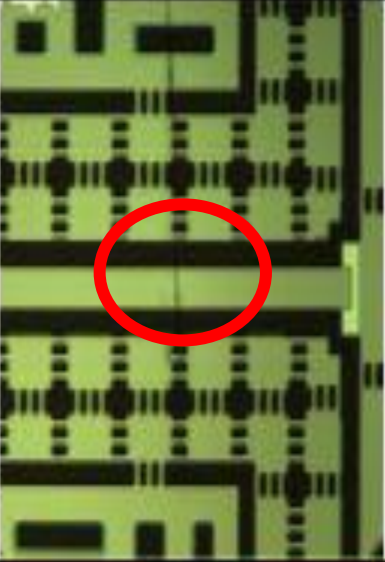
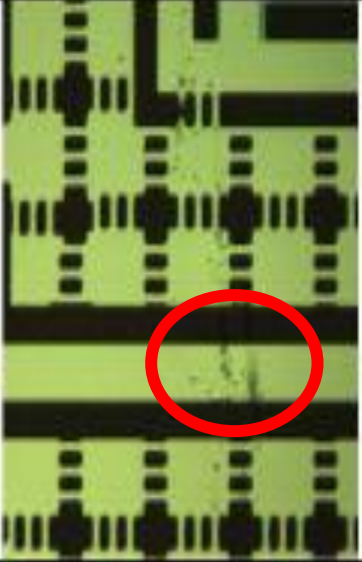
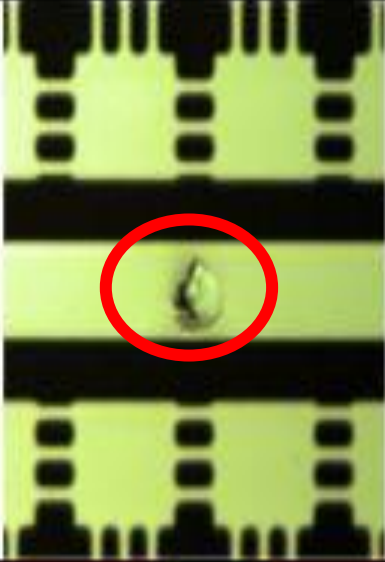
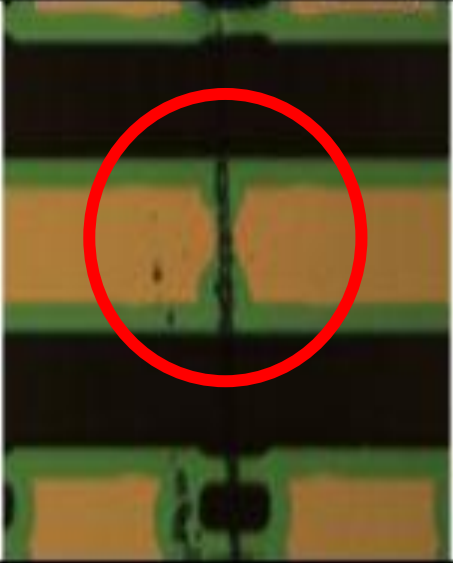
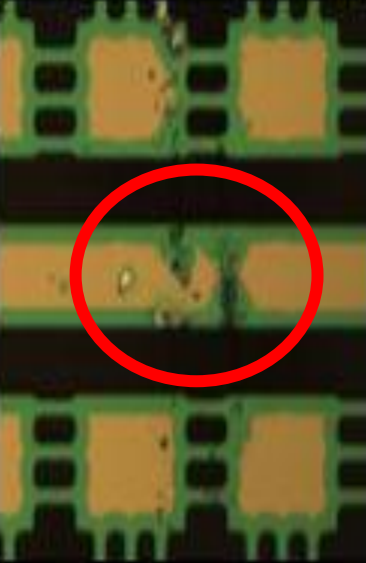



No. of cracks or Permeation

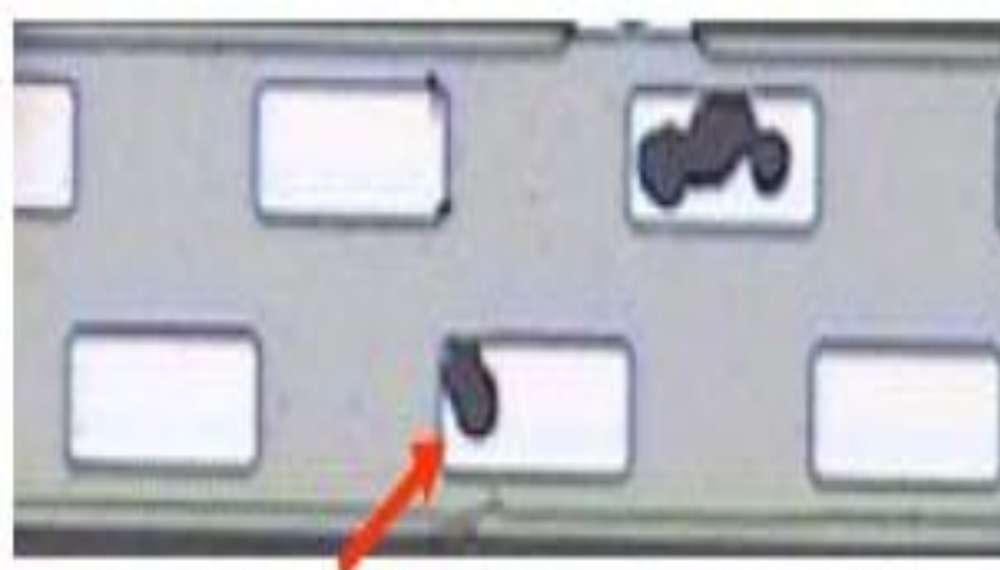


Elongation or % Strain

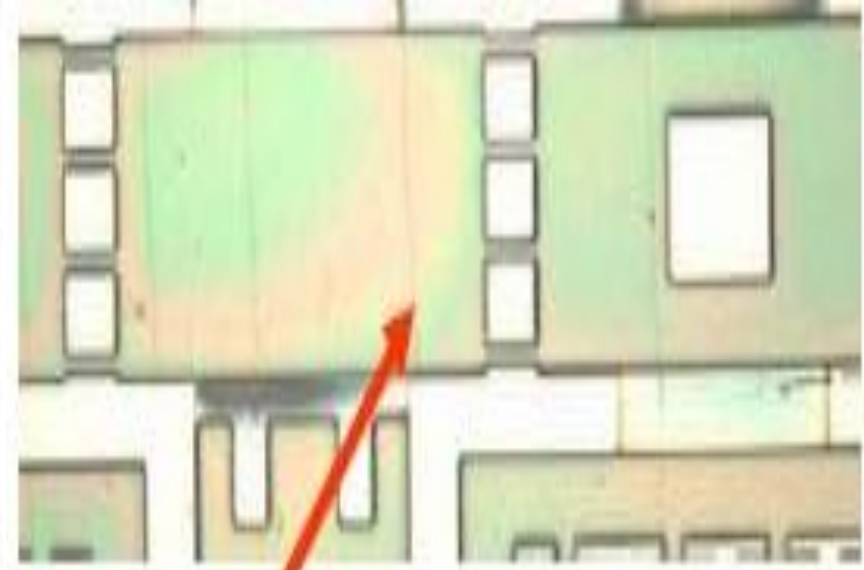


	Scratch	Nodules	Particle embedded in stack
After full processing			
Without top metal			

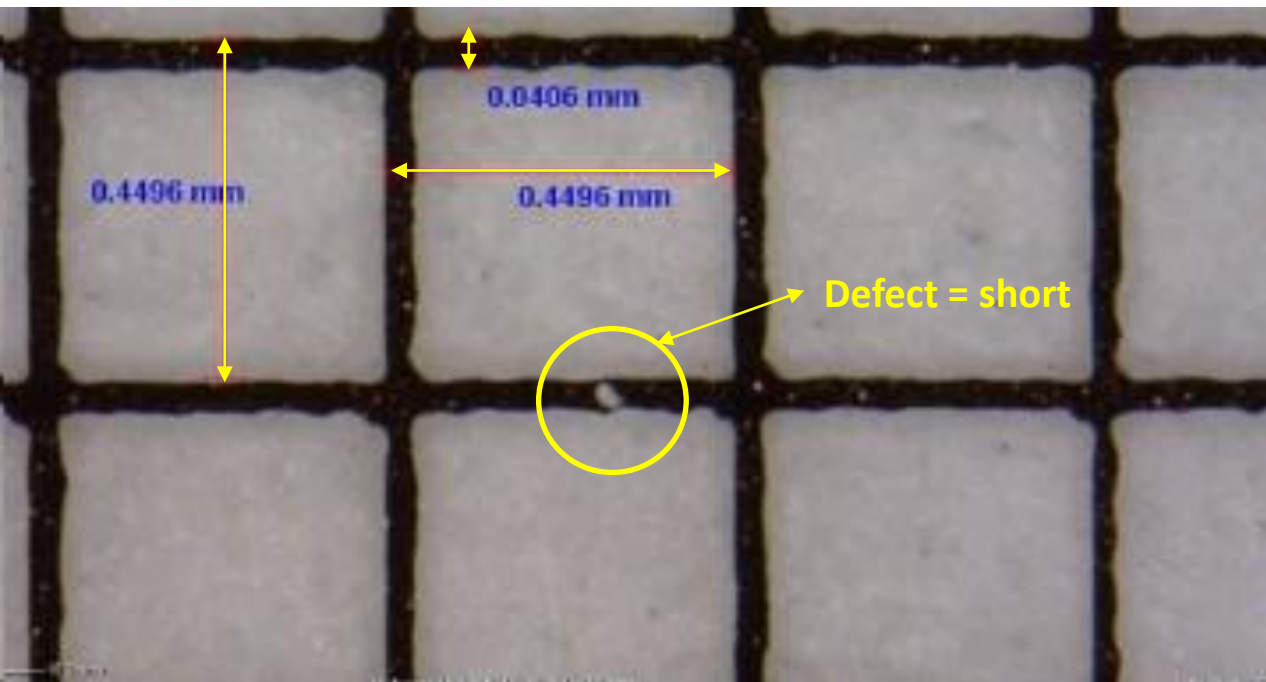
Source: HP labs. Planarisation of PI substrates for R2R for flex displays



pinhole defect in metal caused by etchant diffusing through pinhole in oxide



A crack defect typically results from imbalanced deposition stress



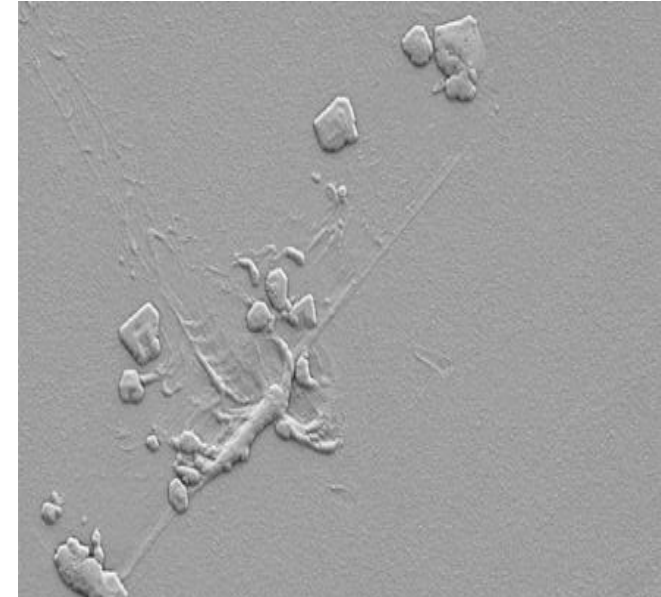
Electronic materials can have poor yields if the surface quality is poor or the tension is not well managed



EHT = 1.00 kV Signal A = SE2 Date :30 Sep 2008
 WD = 5.3 mm Mag = 12.84 K X FHG IPA 350



200 nm EHT = 1.00 kV Signal A = SE2 Date :30 Sep 2008
 WD = 5.3 mm Mag = 23.22 K X FHG IPA 350 ZEISS

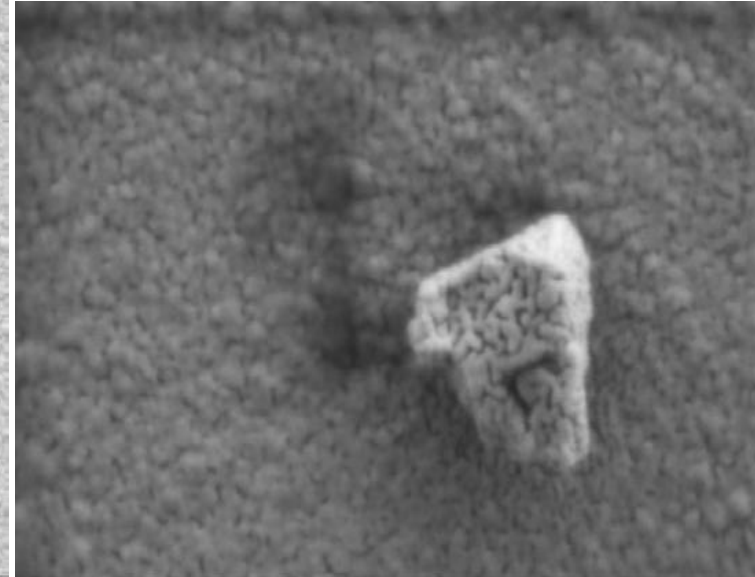


2 µm EHT = 1.00 kV Signal A = SE2 Date :30 Sep 2008
 WD = 5.3 mm Mag = 7.48 K X FHG IPA 350 ZEISS

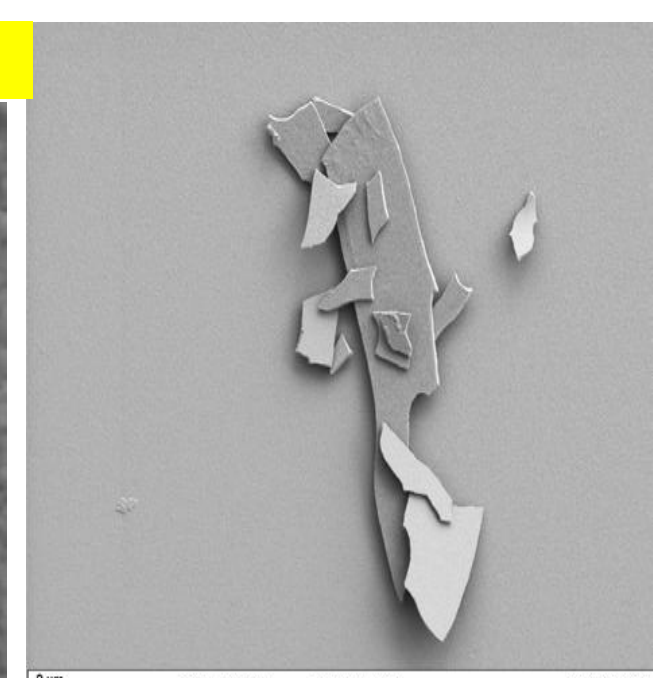
SEM of defects – FEP IVV Freising



200 nm EHT = 1.00 kV Signal A = SE2
 WD = 5.3 mm Mag = 30.74 K X

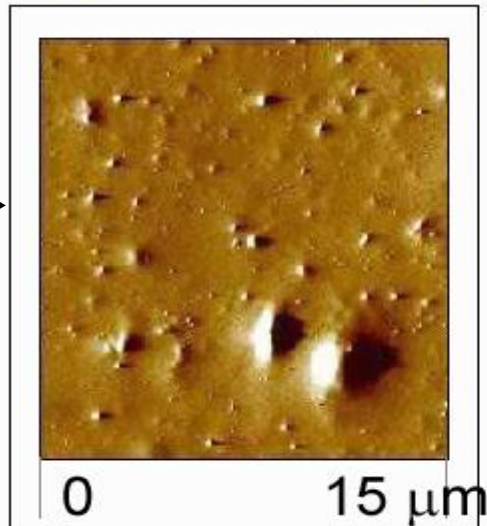


200 nm EHT = 1.00 kV Signal A = SE2 Date :30 Sep 2008
 WD = 5.3 mm Mag = 86.95 K X FHG IPA 350 ZEISS

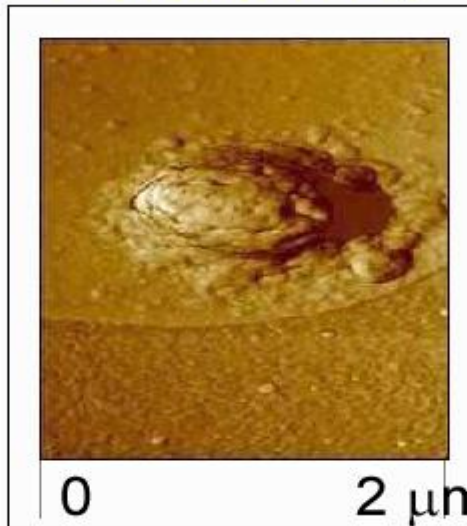


2 µm EHT = 1.00 kV Signal A = SE2 Date :30 Sep 2008
 WD = 5.3 mm Mag = 3.03 K X FHG IPA 350

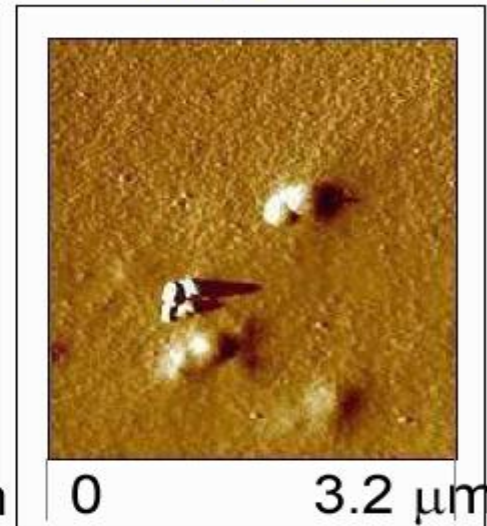
Defects of various sizes



Silica Anti-blocking

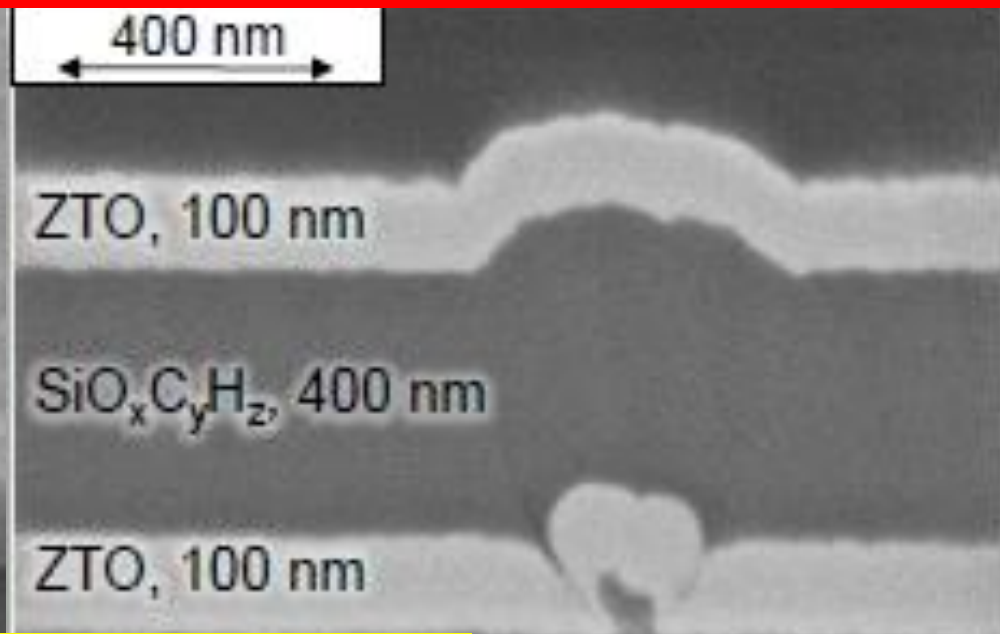
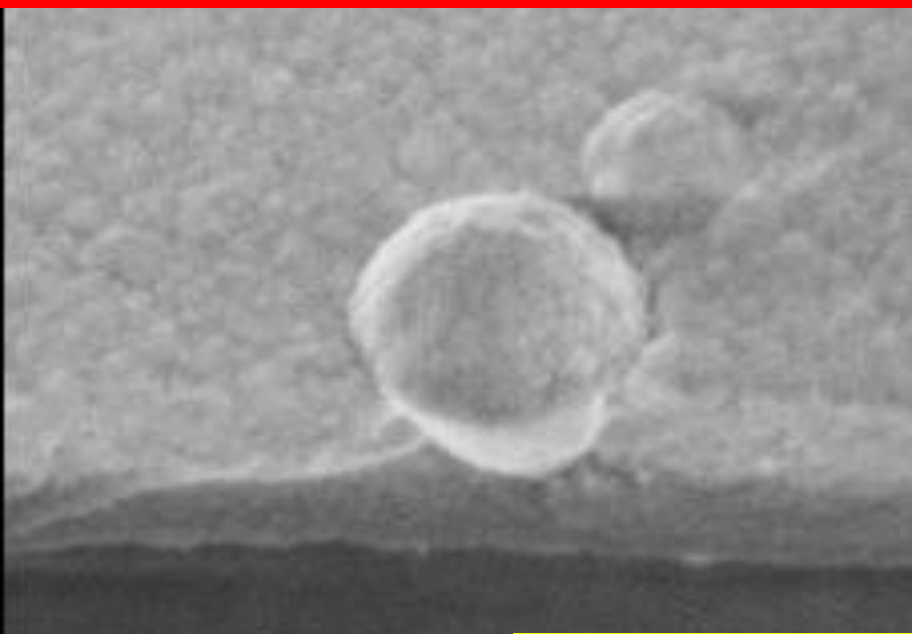


Dust particles



Images courtesy of TetraPak →

Data from tapping AFM: Amplitude



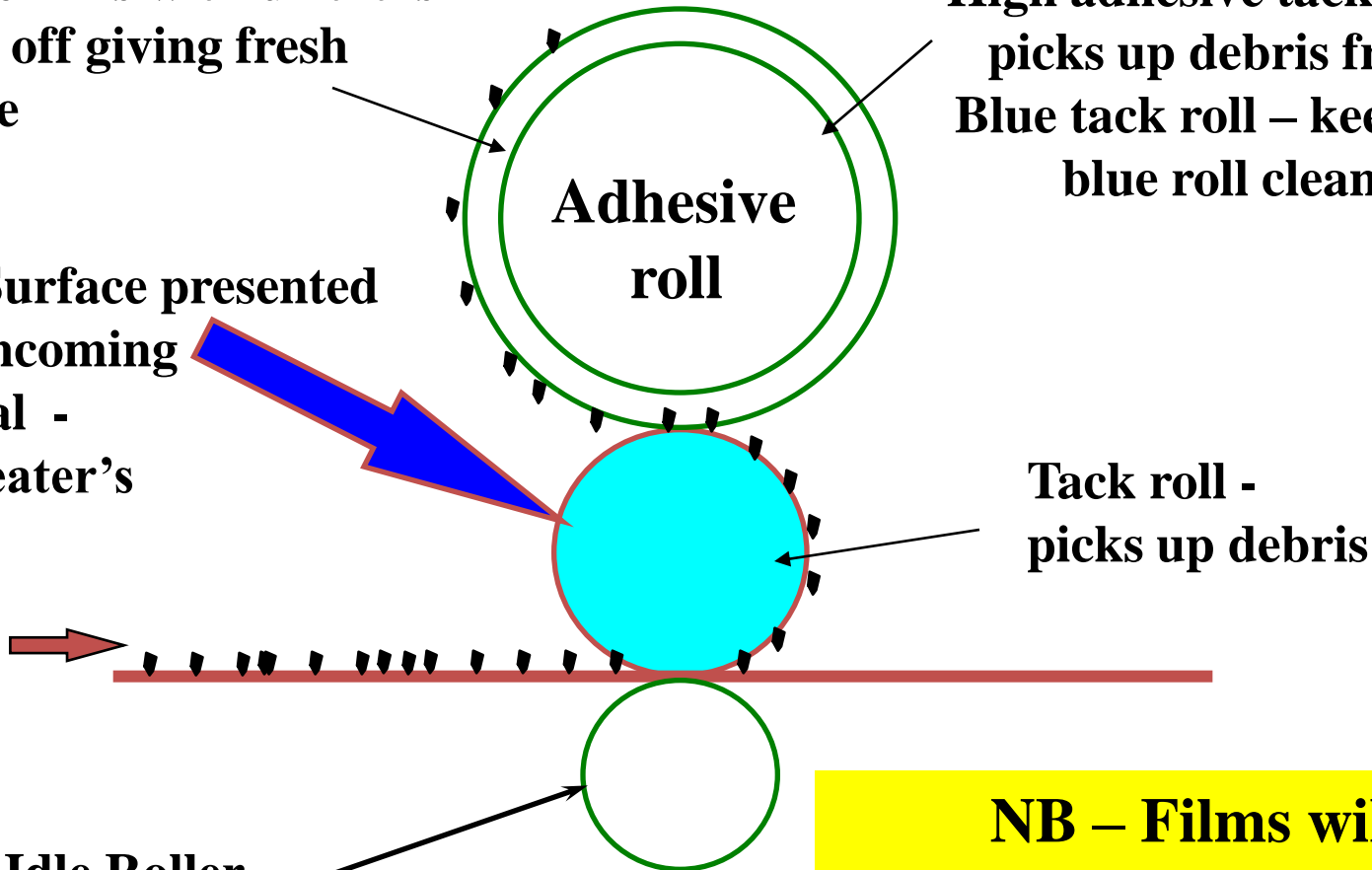
SEM of nodule defects – FEP Dresden

Tack roll cleaning

**High adhesive tack roll -
As layer fills with dirt it is
peeled off giving fresh
surface**

**High adhesive tack roll -
picks up debris from
Blue tack roll – keeping
blue roll clean**

**Clean Surface presented
to the incoming
Material -
No repeater's**

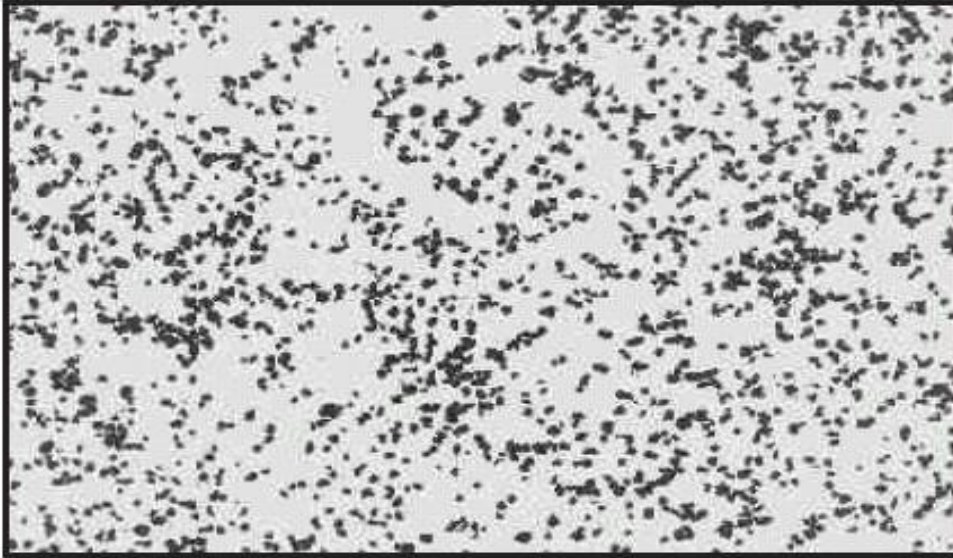


**Tack roll -
picks up debris**

**Idle Roller -
provides nip**

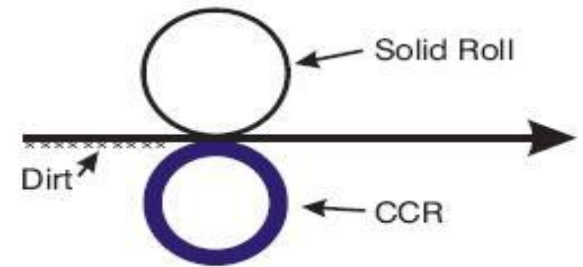
**NB – Films will be
contaminated on both sides –
so BOTH sides need cleaning**

Tacky roll cleaning



Before Cleaning
Particle Count = 2828

(10 micron particles on film)
Photographed at 125X magnification

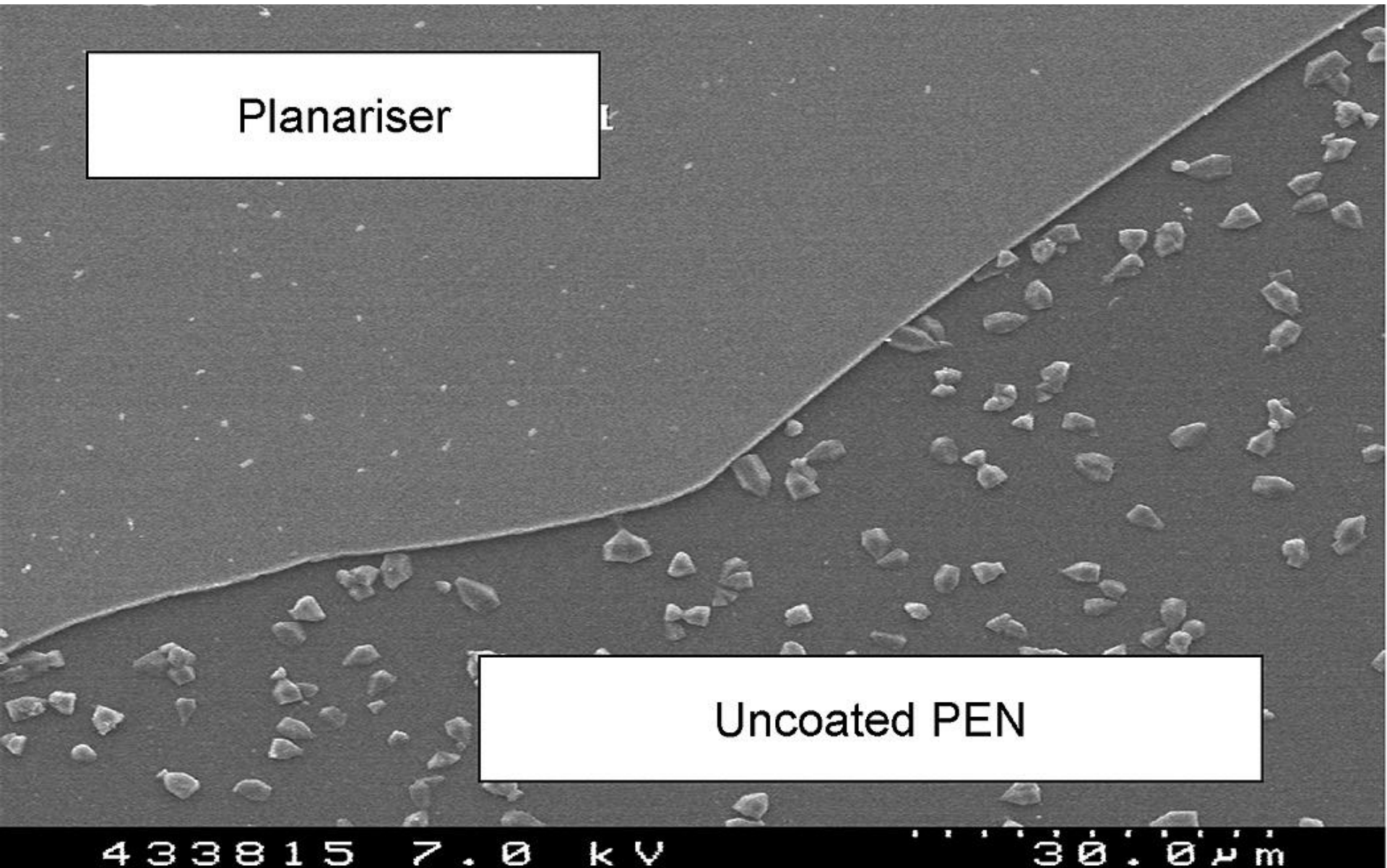


After Cleaning
Particle Count = 87

Images
courtesy of
PolymagTek

Cleaning Efficiency = 96.9%

Planarised substrate



Conclusions

- **Choose polymer type**
- **Heat stabilise web**
- **Clean surface**
 - **Gross clean – particulates**
- **Coat planarising layer**
- **Surface treatment (plasma) – optimise adhesion**
- **Deposit inorganic coating**
 - **option – densify coating**
- **Coat protective layer**
- **Throughout manage tension and heat load**



CONSULTING LTD

Thank you for listening

Charles A. Bishop

C.A.Bishop Consulting Ltd

www.cabuk1.co.uk